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Sheet 1 of 5 sheet(s)

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| U.S. Department of Commerce, Patent and Trademark Office | | Docket No. | Serial No. |
| (PTO Form 1449 modified) | | APPM/5621 | 09/734,950 |
| LIST OF PATENTS AND PUBLICATIONS CITED BY APPLICANT | | Applicant | Confirmation No.: |
| (Use several sheets if necessary) | | Mak, et al. | |
| Examiner Unknown | | Filing Date | Group |
| | | December 11, 2000 | Unknown |

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| Examiner | Binh Tran | Date Considered 6/12/03 |

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with your communication to applicant.

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| (Use several sheets if necessary) | | Filing Date | Group |
| Examiner Unknown | | December 11, 2000 | Unknown |

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| INFORMATION DISCLOSURE STATEMENT BY APPLICANT | | Applicant Mak, et al. | Confirmation No.: 3444 |
| (Use several sheets if necessary) | | Filing Date December 11, 2000 | Group 2874 |
| Examiner | Unknown | | |

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Examiner Binh Tran

Date Considered 6/11/03

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| U.S. Department of Commerce, Patent and Trademark Office (PTO Form 1449 modified) | | Docket No. AMAT/5621/DISPLAY/ AKT/BG | Serial No. 09/734,950 |
| SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT BY APPLICANT | | Applicant MAK, ET AL. | Confirmation No.: 3444 |
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| Examiner TRAN, BINH X. | | | |

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